## **CLAIMS**

## What is claimed is:

1. A method for supporting wafers for singulation and pick-and-place, comprising: providing a semiconductor wafer; mounting an adhesive-coated tape to a surface of the semiconductor wafer; singulating the semiconductor wafer into individual components, leaving a ring of material about a periphery thereof; and removing at least some individual components from the adhesive-coated tape.

- 2. The method of claim 1, further including gripping the semiconductor wafer by the ring of material during the removing of the at least some individual components.
- 3. The method of claim 1, further including forming the ring of material from material of the semiconductor wafer.
- 4. The method of claim 1, further including forming at least a portion of the ring of material from a polymer material disposed about a periphery of the semiconductor wafer.
- 5. The method of claim 1, further including forming the ring of material in part from material of the semiconductor wafer and in part from a polymer disposed about a periphery of the semiconductor wafer.
- 6. The method of claim 5, further comprising forming the ring of material from the polymer material by one of spin-coating, stereolithography or molding.
- 7. The method of claim 1, further comprising backgrinding the semiconductor wafer prior to singulation.

- 8. The method of claim 7, further comprising mounting the adhesive-coated tape to an active surface of the semiconductor wafer and singulating the semiconductor wafer from a backside thereof after backgrinding.
- 9. The method of claim 7, further comprising mounting the adhesive-coated tape to a backside of the semiconductor wafer and singulating the semiconductor wafer from an active surface thereof.
- 10. The method of claim 1, further comprising mounting the adhesive-coated tape to a backside of the semiconductor wafer and singulating the semiconductor wafer from an active surface thereof.
- 11. The method of claim 1, wherein mounting the adhesive-coated tape comprises mounting a tape bearing a UV-sensitive adhesive thereon.
- 12. The method of claim 11, further comprising exposing the UV-sensitive adhesive prior to removing the at least some individual components, but for a portion on the adhesive-coated tape extending over the ring of material.
- 13. The method of claim 1, wherein the semiconductor wafer is singulated using one of laser cutting, water cutting and sawing.
- 14. The method of claim 1, further comprising discarding the ring of material, any remaining individual components and the adhesive-coated tape after removing the at least some individual components.

- 15. An in-process semiconductor structure, comprising:
  a semiconductor wafer having an adhesive-coated tape adhered to one of an active surface and a backside thereof, the adhesive-coated tape being sized and configured to substantially conform to a periphery of the semiconductor wafer;
- wherein the semiconductor wafer includes a plurality of singulated semiconductor dice surrounded by a continuous, peripheral ring of material.
- 16. The in-process semiconductor structure of claim 15, wherein the continuous, peripheral ring of material comprises material of the semiconductor wafer.
- 17. The in-process semiconductor structure of claim 15, wherein the continuous, peripheral ring of material comprises a polymer material disposed about the periphery of the semiconductor wafer.
- 18. The in-process semiconductor structure of claim 15, wherein the continuous, peripheral ring of material comprises material of the semiconductor wafer and a polymer material disposed about the periphery of the semiconductor wafer.
- 19. The in-process semiconductor structure of claim 15, wherein the adhesive of the adhesive-coated tape comprises a UV-sensitive adhesive.
- 20. The in-process semiconductor structure of claim 15, further comprising a holder gripping the continuous, peripheral ring of material from thereabove and therebelow and having a central opening exposing the plurality of singulated semiconductor dice and a portion of the adhesive-coated tape extending thereover.
- 21. The in-process semiconductor structure of claim 20, wherein the adhesive of the adhesive-coated tape comprises a UV-sensitive adhesive.

- 22. The in-process semiconductor structure of claim 21, wherein the holder includes a peripheral annular portion aligned with and extending over a portion of the adhesive-coated tape overlying the continuous, peripheral ring of material.
- 23. The in-process semiconductor structure of claim 22, wherein a portion of the UV-sensitive adhesive within the central opening has been exposed to UV radiation to release the plurality of singulated semiconductor dice therefrom.
- 24. The in-process semiconductor structure of claim 20, wherein the holder is a clamshell-style holder, comprising: an upper, annular portion having a central opening therethrough; a lower, annular portion having a central opening therethrough; and structure for mutually attaching the upper and lower annular portions.
- 25. A method for processing a semiconductor wafer, comprising: singulating a semiconductor wafer into individual components and removing at least some singulated individual components without using a film frame.
- 26. The method of claim 25, wherein the semiconductor wafer is a 300 mm semiconductor wafer and further including handling the 300 mm semiconductor wafer using equipment sized to handle 200 mm semiconductor wafers.
- 27. The method of claim 26, further including singulating the 300 mm semiconductor wafer using a 200 mm semiconductor wafer saw chuck.
- 28. The method of claim 26, further including holding the 300 mm semiconductor wafer in a 200 mm semiconductor wafer pick-and-place machine chuck while removing the at least some singulated individual components therefrom.

- 29. A method of processing a semiconductor wafer, comprising: singulating a semiconductor wafer into individual components while leaving an uncut peripheral ring of material thereabout.
- 30. The method of claim 29, further including removing at least some singulated individual components therefrom.
- 31. The method of claim 30, further including gripping the uncut peripheral ring of material while removing the at least some singulated individual components therefrom.
- 32. The method of claim 29, further comprising defining the uncut peripheral ring of material from semiconductor material.
- 33. The method of claim 29, further comprising defining the uncut peripheral ring of material at least in part from a polymer disposed about the semiconductor wafer.
- 34. The method of claim 29, further comprising defining the uncut peripheral ring of material in part from semiconductor material and in part from a polymer disposed about a periphery of the semiconductor wafer.
- 35. The method of claim 30, wherein the semiconductor wafer is a 300 mm semiconductor wafer and further including handling the 300 mm semiconductor wafer using equipment sized to handle 200 mm semiconductor wafers.
- 36. The method of claim 35, further including singulating the 300 mm semiconductor wafer using a 200 mm semiconductor wafer saw chuck.
- 37. The method of claim 35, further including holding the 300 mm semiconductor wafer in a 200 mm semiconductor wafer pick-and-place machine chuck while removing the at least some singulated individual components therefrom.

- 38. A method of using a 300 mm semiconductor wafer, including handling the 300 mm semiconductor wafer with equipment sized to handle 200 mm semiconductor wafers.
- 39. The method of claim 38, further including processing the 300 mm semiconductor wafer with equipment sized to handle 200 mm semiconductor wafers.
- 40. A wafer holder, comprising: an upper, annular portion having a central opening therethrough; a lower, annular portion having a central opening therethrough; and structure for mutually attaching the upper and lower annular portions.
- 41. The wafer holder of claim 40, wherein the wafer holder is a clamshell-style holder, and the structure for mutually attaching the upper and lower annular portions comprises a hinge.